



IPW

IN THE U.S. PATENT AND TRADEMARK OFFICE

Appl. No. : 10/727,901  
Applicant : Rosenbluth, Alan E.  
Filed : December 4, 2003  
TC/AU : 2851  
Examiner : Gutierrez, Kevin C.

Docket No. : YOR920030339US1  
Customer No. : 29683

Title : PRINTING A MASK WITH MAXIMUM POSSIBLE PROCESS WINDOW  
THROUGH ADJUSTMENT OF THE SOURCE DISTRIBUTION

Mail Stop Non-Fee Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT**

Sir:

In response to the Office Action dated July 22<sup>nd</sup>, 2005, please amend the above-identified application as follows.

**Amendments to the Specification** begins at page 2 of this paper.

**Amendments to the Claims** begins at page 3 of this paper.

**Amendments to the Drawings:** None.

**Remarks/Arguments** begins at page 5 of this paper.

**Appendix:** None.

Applicant believes that the filing of this paper is within the allotted shortened statutory period for reply. However, should the undersigned attorney be mistaken, please consider this a petition for an extension of time that may be required to maintain the pendency of this patent application, and charge Deposit Account No. 50-0510 for any required fee deficiency.